

IN THE SPECIFICATION:

Please amend the paragraph at page 18, line 7, as follows:

Commercially available monomers include a hydroxyl-terminated polyalkylene glycol mono(meth)acrylate manufactured by Nippon Yushi Co., Ltd. such as Blenmer PE-90, Blenmer PE-200, Blenmer PE-350, Blenmer AE-90, Blenmer AE-200, Blenmer AE-400, Blenmer PP-1000, Blenmer PP-500, Blenmer PP-800, Blenmer AP-150, ~~blenmer~~ Blenmer AP-400, Blenmer AP-550, Blenmer AP-800, Blenmer 50PEP-300, Blenmer 70PEP-350B, Blenmer AEP Series, Blenmer 55PET-400, Blenmer 30PET-800, Blenmer 55PET-800, Blenmer AET Series, Blenmer 30PPT-800, Blenmer 50PPT-800, Blenmer 70PPT-800, Blenmer APT Series, Blenmer 10PPB-500B, Blenmer 10APB-500B and the like. Similarly, there are an alkyl-terminated polyalkylene glycol mono(meth)acrylate manufactured by Nippon Yushi Co., Ltd. such as Blenmer PME-100, Blenmer PME-200, Blenmer PME-400, Blenmer PME-1000, Blenmer PME-4000, Blenmer AME-400, Blenmer 50POEP-800B, Blenmer 50AOEP-800B, Blenmer PLE-200, Blenmer ALE-200, Blenmer ALE-800, Blenmer PSE-400, Blenmer PSE-1300, Blenmer ASEP Series, Blenmer PKEP Series, Blenmer AKEP Series, Blenmer ANE-300, Blenmer ANE-1300, Blenmer PNEP Series, Blenmer PNPE Series, Blenmer 43 ANEP-500, Blenmer 70ANEP-550, and products manufactured by Kyoei Chemicals Co., Ltd. such as Light Ester MC, Light Ester 130MA, Light Esters 041MA, Light Acrylate BO-A, Light Acrylate EC-A, Light Acrylate MTG-A, Light Acrylate 130A, Light Acrylate DPM-A, Light Acrylate P-200A, Light Acrylate NP-4EA, Light Acrylate NP-8EA and the like. BO-A, Light Acrylate EC-A, Light Acrylate MTG-A, Light Acrylate 130A, Light Acrylate DPM-A, Light Acrylate P-200A, Light Acrylate NP-4EA, Light Acrylate NP-8EA and the like.

Please amend the paragraph at page 38, line 13, as follows:

To more effectively inhibit the alkali-soluble polymer from dissolving in the developing solution, and at the same time, to impart the increased scratch resistance to the surface portion of the image recording layer, it is preferable that the image ~~recording~~ recording layer further comprise polymers including a (meth)acrylate monomer having two or three perfluoroalkyl groups with 3 to 20 carbon atoms in the molecule thereof, as described in JP KOKAI No. 2000-187318. Such a polymer may be contained in an amount of 0.1 to 10% by weight, more preferably 0.5 to 5% by weight of the total weight of materials for the image recording layer.

Please amend the paragraph at page 53, line 14, as follows:

Anionic surfactants which can be used in the present invention preferably include fatty alcohol sulfuric ester salts such as sodium lauryl alcohol sulfate, ammonium lauryl alcohol sulfate and sodium octyl alcohol sulfate, higher alkyl ether sulfate salts, aryl ether sulfate salts, alkyl aryl sulfonate salts such as sodium isopropyl naphthalene sulfonate, sodium isobutyl naphthalene sulfonate, sodium dodecyl benzene sulfonate ~~and sodium methanito benzene sulfonate~~, sulfuric esters of fatty alcohol having carbon atoms of from 8 to 22 such as sodium secondary alcohol sulfate, aliphatic alcohol phosphoric ester salts such as sodium cetyl alcohol phosphate, alkyl amide sulfonate salts such as $C_{17}H_{33}CON(CH_3)CH_2CH_2SO_3Na$, sulfonate salts of bibasic aliphatic ester such as dioctyl sodium sulfosuccinate and dihexyl sodium sulfosuccinate, hydroxyalkane sulfonate salts, alkane sulfonate salts, alkyl diphenylether sulfonate salts, diphenylether disulfonate salts, dialkyl

sulfosuccinate salts, olefin sulfonate salts, linear alkyl benzene sulfonate salts, branched alkyl benzene sulfonate salts, alkyl naphthalene sulfonate salts, alkyl phenoxy polyoxyethylene propyl ~~sulfonate~~ sulfonate salts, polyoxyethylene alkyl sulfophenylether salts, disodium N-alkyl sulfosuccinate monoamide, petroleum sulfonates, and the like.

Please amend page 70, line 7, as follows:

(trade name of ~~Megafac F-177~~ to Megaface F-177 manufacture by

Please amend page 73, line 16, as follows:

(trade name of ~~Megafac F-177~~ to Megaface F-177 manufacture by

Please amend page 75, line 17, as follows:

(trade name of ~~Megafac F-177~~ to Megaface F-177 manufacture by

Please amend page 75, line 27, as follows:

(trade name of ~~Megafac F-177~~ to Megaface F-177 manufacture by

Please amend Table 1 at page 79, as follows:

Table 1

SiO ₂ - containing Developing Solution No.	Compounds a~z	Concen- tration (g/liter)	Nonreducing Non- reducing sugar- containing Developing Solution No.	Compounds a~z	Concen- tration (g/liter)
(1)	a	0.01	(31)	A	0.01
(2)	a	0.1	(32)	A	0.1
(3)	a	1.0	(33)	A	1.0
(4)	a	10.0	(34)	A	10.0
(5)	a	100.0	(35)	A	100.0
(6)	b	1.0	(36)	B	1.0
(7)	c	1.0	(37)	C	1.0
(8)	d	1.0	(38)	D	1.0
(9)	e	1.0	(39)	E	1.0
(10)	f	1.0	(40)	F	1.0
(11)	g	1.0	(41)	G	1.0
(12)	h	1.0	(42)	h	1.0
(13)	i	1.0	(43)	i	1.0
(14)	j	1.0	(44)	j	1.0
(15)	k	1.0	(45)	k	1.0
(16)	l	1.0	(46)	l	1.0
(17)	m	1.0	(47)	m	1.0
(18)	n	1.0	(48)	n	1.0
(19)	o	1.0	(49)	o	1.0
(20)	p	1.0	(50)	p	1.0
(21)	q	1.0	(51)	q	1.0
(22)	r	1.0	(52)	r	1.0
(23)	s	1.0	(53)	s	1.0
(24)	t	1.0	(54)	t	1.0
(25)	u	1.0	(55)	u	1.0
(26)	v	1.0	(56)	v	1.0
(27)	w	1.0	(57)	w	1.0
(28)	x	1.0	(58)	x	1.0
(29)	y	1.0	(59)	y	1.0
(30)	z	1.0	(60)	z	1.0
(61)	-	-	(62)	-	-